

L.1: Development of GaAs detectors for fast response hard X-ray detection

High-speed detection of hard X-rays requires higher-Z materials such as GaAs to meet the competing demands of high X-ray absorption and fast response. Owing to its higher absorption coefficient, GaAs requires a much smaller thickness than silicon for the same absorption, reducing carrier transit time and enabling faster response. Figure L.1.1(a) shows the electron transit times in Si and GaAs for X-ray energies from 10 to 30 keV, assuming 90% absorption, justifying GaAs-based hard X-ray detectors with nanosecond response. In this context, the Semiconductor Lasers and Devices Division, RRCAT, has already demonstrated GaAs p-i-n X-ray detectors, where the X-ray response is maximum at around 12 keV. [1] At higher energy, the response falls because of decrease in absorption coefficient. Thus, to extend the measurable X-ray energy range, a thicker absorption region is required. Accordingly, detectors based on a 350 μm -thick semi-insulating (SI) GaAs have been developed with optimized planar Ohmic contact and circular Schottky contact of diameter 2 mm on either side of GaAs. Prior to metallization the semiconductor is thoroughly cleaned chemically. Ohmic contact is made with sequential deposition of Au-Ge/Ni/Au followed by rapid thermal annealing at 450 $^{\circ}\text{C}$. On the other hand, Schottky contacts of diameter 2 mm are made using Ti/Au metallization through a shadow metal mask. [2] Figure L.1.1(b) shows the detector mounted on a custom-designed printed circuit board. Reverse-bias measurements up to 100 V yield a leakage current of 15 nA at room temperature, which reduces to 0.8 nA at 280 K (Fig. L.1.2c and inset). A total of six such detectors are made with all of them showing room temperature leakage current below 15 nA.

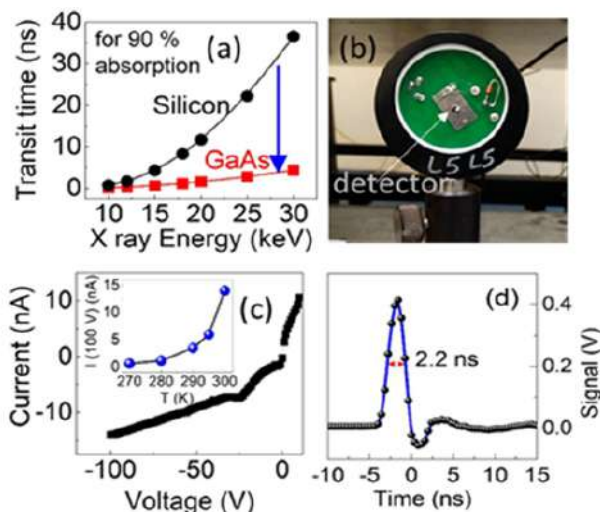


Fig. L.1.1 (a) Electron transit time in Si and GaAs Vs X-ray energy, (b) Photograph of mounted detector; (c) Room temperature I-V of the detector and leakage current as a function of temperature, (d) Temporal response of the detector

The detector operational properties are readily assessed using visible and near-IR illumination. A peak responsivity of 0.15 A/W at 870 nm, along with a spectrally flat response in the 600–800 nm range, is observed, which is typical for GaAs-based photodetectors. To measure the temporal response of the detector, a readout circuit is developed and the voltage signal is measured across 100 Ω resistance using a fast oscilloscope following incidence of Ti:Sapphire femtosecond laser pulse (pulse duration ~ 35 fs). The detector response was measured to be 2.2 ns, as shown in Fig. L.1.1(d), validating the fast carrier extraction capability of the device. The temporal response for X-ray detection is expected to be similar.

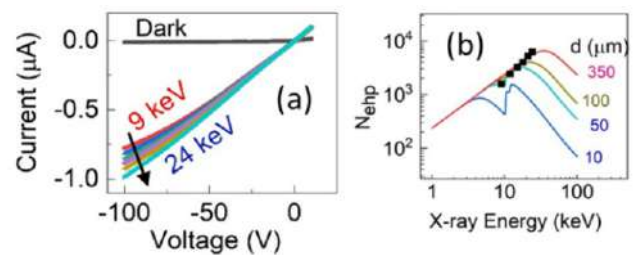


Fig. L.1.2 (a) I-V in dark and in presence of X ray with increasing energy, (b) Comparison of normalized current (black dots) with calculation (solid lines), N_{ehp} is the total number of electron hole pair created under x-ray illumination.

The detector response in the 9–24 keV range was measured in 3 keV steps at beamline-4 (imaging beamline) of Indus-2. A key observation is that at 9 keV the signal magnitude saturates at high bias, whereas at 24 keV it increases linearly with voltage. This is explained by invoking the partial absorption of 24 keV X-ray within the depletion region. [2]

The spectral response of the detector is estimated by normalizing the current at 100 V for each X-ray energy with respect to the measured flux at that energy. In Fig. L.1.2b, these normalized results are shown and the magnitude of signal is observed to increase with X-ray energy. The calculated spectral responses for detector with different thickness are also plotted as solid lines for direct comparison. [2] In summary, we have developed and characterized GaAs based hard X-ray detector operating in the energy range of 9 to 24 keV, which has a time response of 2.2 ns. Cooling of the device by ~ 30 $^{\circ}\text{C}$ is shown to further improve the device performance.

References:

1. Geetanjali et al., Nucl. Inst. Meth. Phys. Res. A, 1084, 171184 (2026)
2. Harsh Tiwari et al., Proceedings of Solid-State Physics Symposium, IIT Roorkie-2025, p-74

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